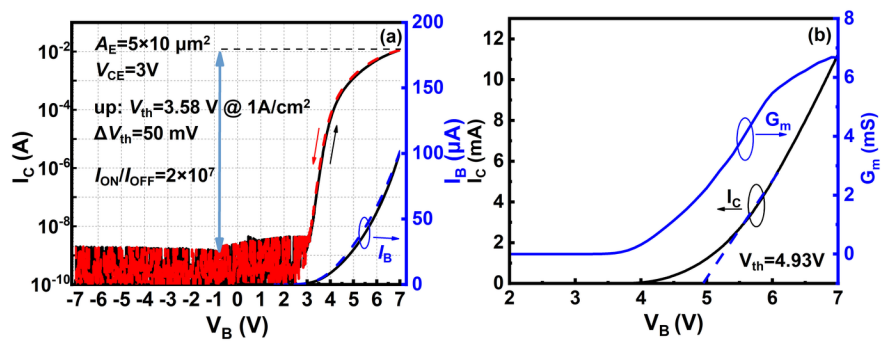




the dynamic $R_{ON,sp}$ is $0.316 \text{ m}\Omega\cdot\text{cm}^2$, which is 4.7% more than the static $R_{ON,sp}$, as shown in Figure 2(b). This value is relatively low among the reported values of GaN HEMTs [14,15]. We attribute the improved dynamic $R_{ON,sp}$ degradation to the vertical current path far from the surface [1]. Slight dynamic $R_{ON,sp}$ degradation may results from defects in the collector and external sub-collector surface traps. Fully vertical GaN-on GaN HBTs can avoid surface traps and reduce the defects in the collector, which is expected to further reduce current collapse.

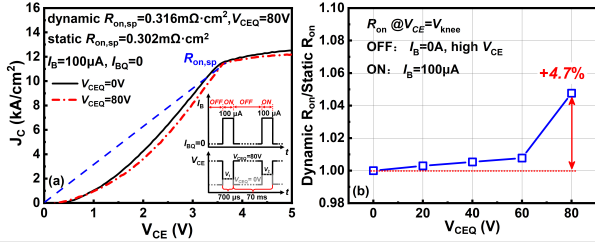


Fig 2 (a) Pulsed I - V characteristics; (b) The ratio of dynamic $R_{ON,sp}$ /static $R_{ON,sp}$ at different V_{CEQ} .

Figure 3 (a) shows the transfer characteristics of the HBT at V_{CE} of 3 V. A V_{th} of 3.58 V is measured at $1 \text{ A}/\text{cm}^2$ with an on/off ratio over 2×10^7 . The V_{th} hysteresis is low to 50 mV between the up- and down- sweep of V_B from -7 to 7 V. This value is relatively low compared with GaN HEMTs, owing to almost eliminated surface state trapping [12,16]. A subthreshold swing (SS) is $190 \text{ mV}/\text{dec}$. The base current is also plotted in Figure 3 (a). The base leakage current is below 10 nA at V_B of -7 V . In the forward operating voltage range of 0 to 7 V , I_B has a very low growth trend to $100 \text{ }\mu\text{A}$, suggesting a sufficient margin for “base” overdrive [4]. As a result, degradation is prevented, even if overshoot voltage occurs during switching. The large voltage margin is important for improving the reliability in power supply circuits. Figure 3(b) gives the transfer curve of the HBT in linear scale. A V_{th} of 4.93 V is evaluated by linear extrapolation of the I_C - V_B curve. The peak current transconductance of the HBT is 6.7 mS .

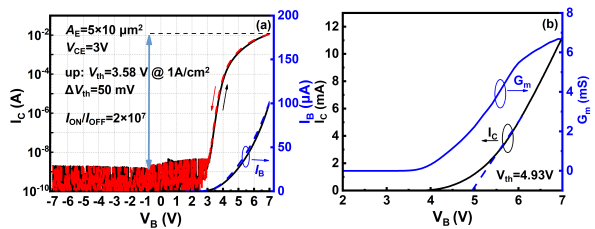


Fig 3 (a) transfer curve in semilog scale and I_B of the HBT; (b) transfer curve in linear scale and transconductance curve.

Conclusion: In summary, we demonstrate the dynamic characteristics of an AlGaIn/GaN HBT with BV_{CEO} of 160 V . A low dynamic $R_{ON,sp}$ of $0.316 \text{ m}\Omega\cdot\text{cm}^2$ at $V_{CEQ}=80 \text{ V}$ is obtained, showing a degradation of 4.7%. The device also exhibits a high V_{th} of 3.58 V with on/off current ratio over 2×10^7 and low V_{th} hysteresis of 50 mV . The base voltage

shows a large swing of $\pm 7 \text{ V}$. These results demonstrate the potential of HBT devices for switching device applications.

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